

<b>FORM HDP-1449 (Based on Form PTO-1449)</b>  <b>PATENT AND TRADEMARK OFFICE</b> <b>INFORMATION DISCLOSURE CITATION</b> (Use several sheets if necessary)  Sheet 1 of 3	ATTORNEY DOCKET No.	SERIAL No.
	8540G-000236/COA	
	APPLICANT	
	Gayatri Vyas et al.	
	FILING DATE	GROUP

U.S. PATENT DOCUMENTS						
Ref. Desig.	Examiner's Initials	Document Number	Date	Name	Class/ Subclass	(If appropriate) Filing Date
RA	1.	RE 37,284	07/17/01	Li, et al.	429/32	
	2.	2002/081478	06-2002	Busenbender, Ilona	429-34	
	3.	3,134,697	11/03/59	Niedrach	136/86	
	4.	3,677,814	07/18/72	Gillery, et.al.	117/211	
	5.	4,146,657	03/27/79	Gordon	427/126	
	6.	4,708,918	11/24/87	Fitzgerald, et al.	429/217	
	7.	4,272,353	06/09/81	Lawrance, et al.	204/283	
	8.	4,510,219	04/09/85	Rowlette		
	9.	4,973,358	11/27/90	Jin, et al.	75/415	
	10.	5,272,017	12/21/93	Swathirajan, et al.	429/33	
	11.	5,334,464	08/02/94	Rowlette	429/210	
	12.	5,624,769	04/29/97	Li et al.	429/32	
	13.	5,800,946	09/01/98	Grosvenor, et al.	429/210	
	14.	5,942,347	08-1999	Koncar, et al.	429/30	
	15.	5,981,072	11/09/99	Mercuri, et al.		
	16.	6,037,074	03-2000	Mercuri, et al.	429/34	
	17.	6,077,623	06/20/00	Grosvenor, et al.	429/210	
	18.	6,096,450	08/01/00	Walsh	429/34	
	19.	6,103,413	08/15/00	Hinton, et al.	429/32	
	20.	6,146,780	11/14/00	Cisar, et al.	429/34	
✓	21.	6,248,467	06/19/01	Wilson et al.	429/39.	

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<b>FORM HDP-1449 (Based on Form PTO-1449)</b>  <b>PATENT AND TRADEMARK OFFICE</b> <b>INFORMATION DISCLOSURE CITATION</b> (Use several sheets if necessary)  Sheet 2 of 3	ATTORNEY DOCKET NO.	SERIAL NO.
	8540G-000236/COA	
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	Gayatri Vyas et al.	
	FILING DATE	GROUP

FOREIGN PATENT DOCUMENTS							
Ref. Desig.	Examiner's Initials	Document Number	Date	Country	Class/ Subclass	Translation Yes	No
1.	RA	EP-A-0933825	08/04/99	Europe		X	
2.		EP-A-0940868	09/08/99	Europe		X	
3.		EP-A-07202349.6	11/11/92	Europe <sup>EP-202343</sup>		X	
4.		EP-A-0975039	01/26/00	Europe		X	
5.		EP-A-983973	05/02/03	Europe		X	
6.		EP-A-0984081	04/02/03	Europe		X	
7.		WO 96/11802	04/25/96	WIPO	B32B	X	
8.		WO98/10477	03/12/98	WIPO		abstract	
9.	↓	WO98/53514	11/26/98	WIPO		X	

OTHER DOCUMENTS (including Author, Title, Date, Pertinent Pages, etc.)		
Ref. Desig.	Examiner's Initials	
1.	RA	M. Hilgendorf, L. Spanhebel, Ch. Rothenhäusler and G. Müller "From ZnO Colloids to Nanocrystalline Highly Conductive Films " in J. Electrochem. Soc., Vol.145, No. 10, October 1998, pages 3632 – 3637.
2.		R. Gordon, Chemical Vapor Deposition of Coatings on Glass, Journal of Non-Crystalline Solids 218 (1997) 81-91
3.		Acosta et al., "About the structural, optical and electrical properties of SnO <sub>2</sub> films produced by spray pyrolysis from solutions with low and high contents of fluorine," Thin Solid Films 288 (1996) 1-7
4.	↓	Ma et al., "Electrical and optical properties of F-doped textured SnO <sub>2</sub> films deposited by APCVD," Solar Energy Materials and Solar Cells 40 (1996) 371-380

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	<b>FILING DATE</b>	<b>GROUP</b>

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)		
Ref. Desig.	Examiner's Initials	
5.	RA	Sekhar et al., "Preparation and study of doped and undoped tin dioxide films by the open air chemical vapor deposition technique," Thin Solid Films 307 (1997) 221-227
6.		Mientus et al, "Structural, electrical and optical properties of SnO <sub>2-x</sub> F-layers deposited by DC-reactive magnetron-sputtering from a metallic target in Ar-O <sub>2</sub> /CF <sub>4</sub> mixtures," Surface and Coatings Technology 98 (1998) 1267-1271
7.		Suh, et al., "Atmospheric-pressure chemical vapor distribution of fluorine-doped tin oxide thin films" Thin Solid Films 345 (1999) 240-243
8.		Perry et al., Chemical Engineers' Handbook Fifth Edition (1973) pp. 68-69
9.	↓	International Search Report dated 6/20/2003; Int'l Appln. No. PCT/US03/05609

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